Corrosion Inhibition of Al-Si-Cu Alloy in the Basic Media by Using Six Inhibitors at Four Temperatures

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Date of acceptance 24/5/2007

Abstract

The research involved attempt to inhibit the corrosion of Al-Si-Cu alloy in $2.5x10^{-3}$ mol.dm ³ NaOH solution (pH=11.4) by addition of six different inhibitors with three concentrations (1x10⁻³, $1x10^{-2}$, and 0.1 mol.dm⁻³). These inhibitors include three organic materials (sodium acetate, sodium benzoate, and sodium oxalate) and three inorganic materials (sodium chromate, disodium phosphate, and sodium sulphate).

The data that concerning polarization behaviour are calculates which include the corrosion potential (E_{corr}) and current density (i_{corr}), cathodic and anodic Tafel slopes ($b_c \& b_a$), and polarization resistance (R_n) .

Protection efficiency (P%) and activation energy (E_a) values were calculated for inhibition by the six inhibitors. The results indicated the effect of temperature on the inhibition in basic media.

Introduction

 The inhibition of corrosion by chemical control of the environment is frequently defined in electrochemical term [1], since corrosion itself is a combination of a least two electrochemical electrode reactions. It follows that if the velocities of either or both of these reactions can be reduced, then some degree of inhibition of the corrosion will be achieved. So a simple definition of inhibitor is: It is a chemical substance, when added in small concentrations to an environment, effectively decreases the corrosion rate of the metal which is exposed to such environment [2].

 The use of the corrosion inhibitors is an important technique in the prevention of metallic corrosion in practice [3] when the presence of the inhibitor brings about a retardation of the corrosion reaction by modifying the processes at the metal solution interface [3].Inhibitors may be classified as anodic, cathodic or mixed inhibitors according to the interference with the corrosion reactions by preferentially attaching themselves to anodic or cathodic areas or whether they attach to both. Anodic inhibitors usually function in neutral or alkaline solutions and act by producing a passivity oxide film primarily at these parts of the

surface where metal cations are formed at anodic sites. Since these sites appear randomly at the surface, the whole surface becomes covered by the passive and protecting film [4, 5].

Cathodic inhibitor act by inhibiting the cathodic regions without greatly affecting the anodic sites. Alternatively, cathodic inhibitors may operate by filming the cathodic areas. Anodic and cathodic inhibitors can be distinguished experimentally by observing the effect they produce on the corrosion potential of the metal, anodic inhibitors shift the corrosion potential to more noble while cathodic inhibitors to more active. Mixed inhibitors, however, which operate by filming the metal surface, affect both the anodic and cathodic processes,thus,the corrosion potential is a little affected.

Lorking and Mayne [6] classified the anions into three categories according to their action on aluminium:

(i) Anions not forming complexes: (a) Nonoxidizing anions such as benzoate, phosphate, and acetate which inhibit corrosion within the neutral range of pH.,

(b) Oxidizing anions such as chromate and nitrate which inhibit corrosion in wider range of pH than class (a).

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(ii) Anions forming soluble complexes with aluminum such as citrate and tartrate. The corrosion rate in the presence of such anions is higher than solution of class (i).

(iii) Anions forming soluble complexes, but cause corrosion of aluminium in neutral solution, such as chlorides.

Materials and Methods

Al-Si-Cu alloy was cut into cylinder shape with (1.7cm)diameter,and made into electrode by pressing a copper wire into a hole on one side and then insulating all but one side with an epoxy resin.

The open side was polished mechanically to a mirror finish,rinsed in distilled water and stored in a desiccators. The chemical composion of alloy was shown in Table (1)which obtained by chemical analysis in Naser Company for mechanical industries. The electrochemical cell was of the usual type with provision for working electrode (Al-Si-Cu alloy),auxiliary electrode (Pt electrode), and a Luggin capillary for connection with an SCE reference electrode.The basic solution was $2.5x10^{-3}$ moldm⁻³NaOH solution (obtained by Ferak with M.wt 40 g .mol⁻¹ and purity >99.5%)which prepare in distilled water (specific conductivity $1x10^{-6}$ S.m⁻¹).

To study effect of inhibition used three concentrations $(1x10^{-3}, 1x10^{-2}, and 0.1)$ mol.dm-3) of six different inhibitors which include sodium acetate,sodium benzoate, sodium oxalate, sodium chromate, disodium hydrogen phosphate, and sodium sulphate.

Electrochemical measurements were performed with a potentiostat (Corroscript) which was obtained from Tacussel (France) at a scan rate of 0.3 Volt per minute. The main results obtained were expressed in terms of the corrosion potentials (E_{corr}) and corrosion current density (i_{corr}) in addition to calculate the cathodic and anodic Tafel slopes by using extrapolation method.

Results and discussion

i- Polarization Curves

The results are reported in fig. (1) and table (2) indicates the polarization behavior of Al-Si-Cu alloy in $2.5x10^{-3}$ mol.dm⁻³ NaOH solution which consist of three stages: **(a)** The cathodic Tafel region (abc section) which representing by migration of electrons

through the surface oxide films and subsequent interaction of those electrons with hydrogen ions and dissolved oxygen at film/solution interface,**(b)** The passivity region (cde section)which due to formation of aluminium oxide (A_2O_3) on a surface, where thermodynamically aluminium an unstable metal and reacts spontaneously with oxygen to give aluminium oxide [7]:

 $4Al + 3O_2 \rightarrow 2Al_2O_3 + 800 \text{ kcal}$ …..(i)

Finally, **(c)** The anodic Tafel region along (efg) section, where the breakdown of the protective film would occur.

The initial reactions in aqueous solution of sodium hydroxide may be represented as [8]:

 $Al + 3H_2O \rightarrow Al(OH)_3 + 3/2H_2$ (ii) This is then followed by the reaction

 $Al(OH)_3 + OH^- \rightarrow AlO_2^- + 2H_2O$ (iii) The net reaction thus being [9]

 $Al + NaOH + H_2O \rightarrow NaAlO_2 + 3/2H_2$ (iv) The reaction (iii) may also be

represented as[10]: *Al(OH)3+NaOH+2H2O→Na⁺+[Al(OH)4.2H² O]¯(v)*

Despite the excellent mechanical and physical properties of the Al-Si-Cu hypereutectic alloy, their corrosion resistance in aggressive environments is not yet well known. Some work has been carried out to evaluate the corrosion resistance of this alloy in alcoholic fuels[11,12].It has been suggested that corrosion of Al-Si-Cu alloy starts at the matrix/precipitate interface [13].

These precipitate particles were rich in Al and Cu,and could therefore be intermetallic CuAl₂.Considering that the electrical conductivities of $Al(3.77 \times 10^{7} \text{ohm})$ $1¹m⁻¹$) and Cu(5.98x10⁷ohm⁻¹m⁻¹ higher than that of Si $(1x10^3 \text{ohm}^{-1}\text{m}^{-1})$, and that the hydrogen evolution reaction is more polarized on Al (i_0 of approximately 10^{-10} A/cm⁻²) than on Cu (i_o around 10^{-7} A/cm⁻²) [14], it is likely that the cathodic hydrogen evolution reaction occurs on the copper rich intermetallic precipitates.

The purpose of this investigation is attempt to inhibit the corrosion of Al-Si-Cu alloy in basic media and to study some of the parameters concerning of polarization behavior.

Figures (2) to (7) show effect of six inhibitors additives to $2.5x10^{-3}$ mol.dm⁻³ NaOH solution with three concentration of each inhibitor $(1x10^{-3}, 1x10^{-2},$ and 0.1 mol.dm⁻ 3) on corrosion of Al-Si-Cu alloy. Addition of these inhibitors shift the corrosion potential (Ecorr) either toward active or noble direction, but addition of these inhibitors lead to shift the corrosion current density (i_{corr}) to lower values.

ii- The Tafel Slopes (b)

The reduction of the H_2O molecule is a common cathodic reaction for the corrosion of metals in neutral and alkaline solutions:

*H*₂*O* + *e* → $1/2H_2$ + *OH*^{$−$} ……(vi)

The hydrogen evolution reaction (h.e.r) has been the most widely studied electrode reaction.

However, it is important to note that the discharge step involves adsorption of hydrogen atoms at available sites on the metal surface, and is followed by desorption that may be either a chemical step, or an electrochemical step in which further charge transfer occurs. A value of the cathodic Tafel slope of $(-0.120 \text{ V}.$ decade⁻¹) may be diagnostic of a proton discharge-chemical desorption mechanism in which the proton discharge is the rate-determining step (r.d.s).

In chemical desorption step the adsorbed H atom diffuse about on the metal surface, either by threading their way through adsorbed water molecules or by pushing them aside, until two collide to form an H_2 molecule which escapes into the solution. This chemical step will be independent of overpotential, since charge transfer is not involved, and the rate will be proportional to the concentration or coverage θ_H of adsorbed Hads and may occur at coverage that range from very small to almost complete.

If the discharge process is followed by a rate-determining step involving chemical desorption (C.D.), the expected value of the cathodic Tafel slope should be (-0.03 $V. decade^{-1}$).

On the other hand, the electrochemical desorption (E.D.) step is far more complex since it involves reaction between an adsorbed H atom, a hydrated proton H_3O^+ and an electron, and for desorption to occur the

proton must discharge onto a hydrogen atom adsorbed on the metal surface.

Under these circumstances the probability of collision well be low unless the coverage θ_H is high. When electrochemical desorption becomes the rate-determining step for (h.e.r) on the cathode, the expected value of b_c will be $(-0.05 \text{ V}.$ decade⁻¹).

In fact, in certain cases the mechanism will change from a C.D. to an E.D. step when the overpotential has attained a sufficiently large value^[15]. The results of tables (3) to (8) show the effect of addition the inhibitors on the rate-determining step which indicates that the cathodic Tafel slopes, in general, ranges from a C.D. to an E.D. step except some cases.

HamiHa and Co-worker[16] observed that the electrochemical process of Al-Si-Cu alloy occurring at high rate is probably due to charge transfer processes associated to reduction of Si to form silicon hydride (at pH=3.3) and the anodic dissolution of the matrix can be balanced by the hydrogen evolution reaction on the intermetallic particles, and by reduction of Si and O_2 .

 $Si+4H+4e \rightarrow SiH_4$ and $O \cdot 4H+4e \rightarrow 2H_2O$

Further, the decrease in kinetics of the anodic process with time, resulting from the conversion of Si to SiH4, would also decrease the overall cathodic reaction rate, and consequently the dissolution (anodic) rate[16].

iii- The Polarization Resistance (Rp)

The polarization resistance (R_p) may be defined as [17, 18]:

$$
R_p = \frac{d(E - E_{corr})}{di} \quad \ldots \ldots (1)
$$

Where E and E_{corr} are the applied corrosion potential (Volt) respectively, I is the current density $(A.cm⁻²)$.

For small polarization, one may write approximation [17,18]:

$$
R_p = \frac{d(E - E_{corr})}{di} = \frac{E_{corr}}{i_{corr}} \quad(2)
$$

where E_{corr} and i_{corr} are the corrosion potential (V) and corrosion current density (A.cm-2). The ratio (E_{corr}/i_{corr}) thus corresponds to the resistance of the metal/solution interface to charge-transfer reaction. It is also a measure of the resistance of the metal to corrosion in the solution in which the metal is immersed. For low-field polarization [19]:

$$
\frac{\eta}{i} = \frac{RT}{Fi_o} \dots (3)
$$

and
$$
\frac{E_{corr}}{i_{corr}} = \frac{RT}{Fi_o} = R_p \dots (4)
$$

Where $\eta = E-E_{corr}$ and i_0 is the equilibrium exchange current density $(A.cm⁻²)$. The reaction resistance (R_p) , which mainly depends upon the equilibrium exchange current density (i_0) determines what may be termed the polarizability, i.e., what overpotential $(\eta=E-E_{corr})$ a particular current density needs or produces since[20]:

$$
R_p = \frac{d\eta}{di} = \frac{d(E - E_{corr})}{di} = \frac{E_{corr}}{i_{corr}} = \frac{RT}{Fi_o} \dots (5)
$$

The polarization resistance (R_p) was also determined in another way from Stern-Geary equation, where:

$$
R_p = \left(\frac{dE}{di}\right)_{i=0} = \frac{b_a b_c}{2.303(b_a + b_c)i_{corr}} \dots (6)
$$

The values of R_p have been calculated from eq.(6), which are presented in tables (2) to (8).

The results of tables (2) to (8) indicates that the R^p of Al-Si-Cu alloy in $2.5x10^{-3}$ mol.dm⁻³ NaOH solution with out addition is lower than its value in the presence of inhibitor in solution. The R_p values increases with increasing concentration of inhibitor except in the presence of acetate and sulphate ions, since the highest value of R_p is notes at $1x10^{-2}$ mol.dm⁻³ of these ions. The order of R_p for solution in presence of inhibitors takes the following sequence:

 R_p 0.1mol.dm⁻³CrO₄⁼>0.1mol.dm⁻

 $3PO_4 = > 1 \times 10^{-2}$ mol.dm⁻³SO₄ > 1x10⁻²mol.dm⁻ ${}^{3}CH_{3}COO$ >0.1mol.dm⁻³ $C_{2}O_{4}^{-}$ > 0.1mol.dm⁻³ ph-COO-

iv- Protection Efficiency (P%)

The corrosion current densities in the presence (i_2) and absence (i_1) of inhibitor in the corrosion medium have been used to determining the protection efficiency (P%) by using the relation:

$$
P\% = 100 \left[1 - \frac{i_2}{i_1} \right] \quad \ldots \ldots (7)
$$

The results in table (9) indicate that the values of P% are positive which indicates the inhibition of corrosion by the added additives to solution of NaOH. When add the lowest concentration of inhibitors, P% were $<60\%$ except in the case of sulphate ions, whileP% increases with increasing the concentration except in the case of acetate and sulphate ions since the highest value of P% was observed at $1x10^{-2}$ mol.dm⁻³ of these inhibitors.

Figure (8) show effect of inhibitor concentration on the protection efficiency. The better protection for Al-Si-Cu alloy observes when add 0.1 mol.dm⁻³ sodium chromate to basic solution.

v- Effect of Temperature

Generally, the increasing of temperature shifts the corrosion potential (Ecorr) toward the noble direction except some case and the corrosion current density (i_{corr}) to the higher values. While, it is observes that in all the cases the extent of inhibition decreased with a rise in temperature (table 9).From the corrosion rates at different temperatures, the values of the activation energy were calculated following the equation[8]:

$$
\log \frac{S_2}{S_1} = \frac{E_{app}^*}{2.303 R} \left[\frac{1}{T_1} - \frac{1}{T_2} \right] \ \dots \dots (8)
$$

where S_1 and S_2 are the corrosion rates at the temperature T_1 and T_2 (K) respectively and E_{app}^* is the activation energy.

The data are given in table (10) may be generalized that the E_{app}^* values are in general higher in presence of the inhibitors than the values in their absence. However, because of the vividness of the E_{app}^* values no specific generalizations could be drawn regarding the relationship between the inhibitor efficiency and the energy of activation. In comparing the activation energies obtained it must be realized that they are only apparent values,i.e.they have been determined at constant bulk inhibitor concentrations. The protection efficiency and the degree of surface coverage θ change with temperature[21]. This change is incorporated in the value of (E_{app}^*) . The more sensitive the protection efficiency

and the degree of surface coverage to temperature changes, the larger are the differences in activation energy between the inhibited and uninhibited solutions. To eliminate this effect, the activation energy should be determined at a constant surface inhibitor activity, i.e. at a constant degree of surface coverage[22].

Also the apparent activation energy (E_{app}^*) depend on the many factors according to the following equation:

 $E_{app}^* = E^* + \beta F(\phi - \psi_2)$ (9)

where E^* the activation energy not depended on the potential of electrode, *β* the transfer coefficient, *F* faraday number, ϕ the total difference in potential at electrical double layer, and *ψ²* Zeta potential.

Where the adsorbent particles which increase the Zeta potential ψ_2 is decreases the apparent activation energy for corrosion reaction, while the adsorbent particles which decrease the Zeta potential *ψ²* lead to increasing in the apparent activation energy.

Discussion of Inhibition Action

The inhibiting action achieved by organic compounds is usually attributed to interactions by adsorption between the inhibitor and the metal surface. Adsorption can be of a purely physical nature by means of electrostatic or Van der Waals forces, which are easily removed from the surface, or a chemical nature which forms chemical compounds. Inhibitor efficiency is higher for a compound which can donate electrons easily for the molecular site of adsorption and corresponds to high electron density at the presumed adsorption center in the molecular. Most organic inhibitors are compounds with at least one polar function; the polar function is regarded as the reaction center for the establishment of the chemisorbed bond, whose strength is determined by the electron density of the atom acting as the reaction center [23].

Generally, organic compounds are adsorbed on the metal surface and interface with either cathodic or anodic reaction occurring at the adsorption site.

Acetate(CH₃COO⁻)and oxalate $(C_2O_4$ ⁼) ions gave rise to small irregularly shaped pits with clear crystallographic features. This observation suggested that the acetate and oxalate ion was neither a passivator nor a blocking inhibitor. Its action must be either to isolate the surface from hydroxide ions by preferential adsorption or to act buffer. While benzoate $(C₆H₅COO⁻)$ ions act as blocking inhibitors by forming insoluble precipitates. It was noticeable that such deposited formed at a slight distance from pits after initiation.This inhibitor arrested pit propagation at an early stage rather than prevented pit initiation.

The bulky molecules limit the diffusion of oxygen to the surface or they trap the metal ions on the surface, reducing the rate of dissolution, while inorganic oxidizing substance that promote the passivity on the surface by shifting the corrosion potential in the noble direction.

Chromates $(CrO₄⁼)$ is efficient inhibitors of the corrosion of aluminium and its alloys. The redox reaction between (Cr^{6+}) ions and aluminium metal, however revealed, occurs, forming alumina and solid chromic oxide[24]:

 $2Al + 3H_2O \rightarrow Al_2O_3 + 6H^+ + 6e$ …(vii) $2CrO_4^2 + 10H^+ + 6e \rightarrow CrO_3 + 5H_2O$ *…(viii)*

Although the valency states of particular chromium-containing species could not be determined, the data were taken to indicate the initial general presence of chromate species which had penetrated the anodic alumina film and the local development, at likely flaw sites, of solid Cr_2O_3 plugs. The local development of Al(OH)3plugs, at anodic sites, the precipitation of which is catalyzed by chromate species, was not discounted.

The data of various workers, using different experimental conditions and examination techniques, suggest that Cr(III) is present predominantly on specimens supporting air-formed film whilst Cr(VI) is detected in the outer regions of specimens supporting relatively thick barrier-type film, with local presence of Cr(III).

Chromate solution greatly decreased the $O₂$ reduction rate on the alloy surface and the cathodic inhibition by Cr(VI) solution was accompanied by a transient reduction current equivalent to generation of approximately a monolayer of Cr(III) oxyhydroxide [25]. On the other hand, chromate is mobile in solution and migrates to exposed areas on the Al alloy surface and adsorbs on the active sites of the surface and is reduced to form a monolayer of a Cr(III) species which is effective at reducing the activity of both cathodic sites and anodic sites in the matrix.The anodic inhibition is related to the inhibition stage of localized corrosion and not propagation [26].

Phosphate (PO_4^{\equiv}) ions behaves same behavior of benzoate ions, generally in benzoate and phosphate solutions more than one pit was initiated and the overlapping of the transient behavior for each pit masked the kinetics of each individual pit. While sulphate (SO⁴ =) ions worked not by healing the film but by displacing the hydroxide ion from the metal surface.

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Element	ມ	ŬИ	Мg		$\mathcal{L}^{\prime\prime}$		Мn	COLLA	- 7.9	Δt
$Wt\%$	\sim \sim \mathbf{x} 12.JU	\sim \sim \sim 3.563	168	0.857	0.683	0.513 1	0.335	0.070	0.049	Bal.

Table (2): Values of corrosion potential(E_{cor}), corrosion current density (i_{cor}), cathodic and anodic Tafel slopes (b_c & b_a), and polarization resistance (R_p) for corrosion of Al-Si-Cu alloy in 2.5x10⁻³ mol.dm⁻³ NaOH solution (pH=11.4) at four temperatures.

\bm{T}		Corrosion	b (V.decade ⁻¹)	$Rp/10^{+4}$	
$\bf(K)$	$-E_{corr}(V)$	$i_{corr}(A.cm^{2})$	$-\boldsymbol{b}_c$	$+b_a$	(Ω, cm^2)
298	.49	$3.305x10^{-6}$	0.120	0.100	0.716
303	.45	3.437×10^{-6}	0.090	0.095	0.583
308	.39	3.613×10^{-6}	0.070	0.089	0.470
313	.35	3.746×10^{-6}	0.065	0.085	0.426

Table (3): Values of corrosion potential(E_{corr}), corrosion current density (i_{corr}), cathodic and anodic Tafel slopes (b_c & b_a), and polarization resistance (R_p) for corrosion of Al-Si-Cu alloy in 2.5x10⁻³ mol.dm⁻³ NaOH solution ($pH=11.4$) in presence of the sodium acetate (CH_3COONa) at four temperatures.

solution (pH=11.4) in presence of the sodium benzoate (C_6H_5COONa) at four temperatures.						
Conc. of	\boldsymbol{T}	Corrosion		b (V.decade ⁻¹)	$Rp/10^{+4}$	
Inhibitor	(K)	$-E_{corr}(V)$	$i_{corr}(A.cm^{2})$	$-bc$	$+b_a$	(Ω, cm^2)
	298	1.55	1.322×10^{-6}	0.050	0.100	1.094
$1x10^{-3}$	303	1.53	1.542×10^{-6}	0.046	0.076	0.806
M ol.dm ⁻³	308	1.50	1.762×10^{-6}	0.041	0.068	0.630
	313	1.48	1.983×10^{-6}	0.040	0.052	0.495
	298	1.47	0.528×10^{-6}	0.071	0.096	3.356
$1x10^{-2}$	303	1.46	0.793×10^{-6}	0.046	0.091	1.673
M ol.dm ⁻³	308	1.45	0.881×10^{-6}	0.041	0.082	1.347
	313	1.44	0.969×10^{-6}	0.034	0.068	1.015
	298	1.44	2.644×10^{-7}	0.130	0.136	10.915
0.1	303	1.43	2.864×10^{-7}	0.034	0.130	4.086
M ol.dm ⁻³	308	1.42	3.085×10^{-7}	0.025	0.125	2.932
	313	1.41	3.305×10^{-7}	0.020	0.088	2.141

Table (4): Values of corrosion potential(E_{corr}), corrosion current density (i_{corr}), cathodic and anodic Tafel slopes (b_c & b_a), and polarization resistance (R_p) for corrosion of Al-Si-Cu alloy in 2.5x10⁻³ mol.dm⁻³ NaOH

Table (5): Values of corrosion potential(E_{corr}), corrosion current density (i_{corr}), cathodic and anodic Tafel slopes (b_c & b_a), and polarization resistance (R_p) for corrosion of Al-Si-Cu alloy in 2.5x10⁻³ mol.dm⁻³ NaOH solution (pH=11.4) in presence of the sodium oxalate (Na₂C₂O₄) at four temperatures.

Æ								
Conc. of	\boldsymbol{T}	Corrosion		b (V.decade ⁻¹)	$Rp/10^{+4}$			
Inhibitor	(K)	$-E_{corr}(V)$	$i_{corr}(A.cm^{2})$	$-b_c$	$+b_a$	(Ω, cm^2)		
$1x10^{-3}$ M ol.dm ⁻³	298	1.52	1.895×10^{-6}	0.060	0.088	0.817		
	303	1.50	1.983×10^{-6}	0.056	0.078	0.713		
	308	1.49	2.203×10^{-6}	0.051	0.065	0.563		
	313	1.48	2.644×10^{-6}	0.042	0.062	0.411		
$1x10^{-2}$ M ol.dm ⁻³	298	1.47	3.217×10^{-7}	0.046	0.100	4.252		
	303	1.46	3.966×10^{-7}	0.042	0.091	3.146		
	308	1.45	4.186×10^{-7}	0.040	0.075	2.706		
	313	1.42	4.407×10^{-7}	0.038	0.060	2.292		
0.1 M ol.dm ⁻³	298	1.45	3.085×10^{-7}	0.044	0.350	5.501		
	303	1.44	3.305×10^{-7}	0.039	0.300	4.534		
	308	1.43	3.525×10^{-7}	0.032	0.211	3.422		
	313	1.42	3.746×10^{-7}	0.027	0.150	2.652		

Table (6): Values of corrosion potential(E_{corr}), corrosion current density (i_{corr}), cathodic and anodic Tafel slopes (b_c & b_a), and polarization resistance (R_p) for corrosion of Al-Si-Cu alloy in 2.5x10⁻³ mol.dm⁻³ NaOH solution($pH=11.4$) in presence of the sodium chromate (Na₂CrO₄) at four temperatures.

solution ($pH=11.4$) in presence of the disodium hydrogen phosphate ($Na2HPO4$) at four temperature-								
Conc. of	\boldsymbol{T}		Corrosion	b (V.decade ⁻¹)	$Rp/10^{+4}$			
Inhibitor	(K)	$i_{corr}(A.cm^2)$ $-E_{corr}(V)$		$-bc$	$+b_a$	(Ω, cm^2)		
	298	1.53	1.718×10^{-6}	0.100	0.120	1.378		
$1x10^{-3}$	303	1.52	1.762×10^{-6}	0.075	0.100	1.056		
M ol.dm ⁻³	308	1.51	1.851×10^{-6}	0.055	0.093	0.810		
	313	1.48	1.955×10^{-6}	0.051	0.091	0.725		
$1x10^{-2}$ M ol.dm ⁻³	298	1.47	0.484×10^{-6}	0.058	0.122	3.526		
	303	1.46	0.528×10^{-6}	0.057	0.112	3.106		
	308	1.45	0.572×10^{-6}	0.050	0.094	2.477		
	313	1.44	0.617×10^{-6}	0.042	0.075	1.894		
0.1 M ol.dm ⁻³	298	1.32	1.057×10^{-7}	0.120	0.125	25.15		
	303	1.29	1.542×10^{-7}	0.110	0.120	16.16		
	308	1.26	1.762×10^{-7}	0.100	0.111	12.96		
	313	1.23	2.203×10^{-7}	0.069	0.100	17.21		

Table (7): Values of corrosion potential(E_{corr}), corrosion current density (i_{corr}), cathodic and anodic Tafel slopes (b_c & b_a), and polarization resistance (R_p) for corrosion of Al-Si-Cu alloy in 2.5x10⁻³ mol.dm⁻³ NaOH solution ($pH=11.4$) in presence of the disodium hydrogen phosphate (Na₂HPO₄) at four temperatures.

Table (8): Values of corrosion potential(E_{conf}), corrosion current density (i_{corr}), cathodic and anodic Tafel slopes (b_c & b_a), and polarization resistance (R_p) for corrosion of Al-Si-Cu alloy in 2.5x10⁻³ mol.dm⁻³ NaOH solution ($pH=11.4$) in presence of the sodium sulphate (Na_2SO_4) at four temperatures.

Conc. of	\boldsymbol{T}	Corrosion		b (V.decade ⁻¹)	$Rp/10^{+4}$	
Inhibitor	(K)	$-E_{corr}(V)$	$i_{corr}(A.cm^{-2})$	$-b_c$	$+b_a$	(Ω, cm^2)
	298	1.43	0.617×10^{-6}	0.060	0.120	2.815
$1x10^{-3}$ M ol.dm ⁻³	303	1.41	0.661×10^{-6}	0.057	0.115	2.503
	308	1.40	1.013×10^{-6}	0.053	0.085	1.399
	313	1.38	1.145×10^{-6}	0.046	0.066	1.027
	298	1.40	1.983×10^{-7}	0.069	0.130	9.870
$1x10^{-2}$	303	1.39	2.071×10^{-7}	0.055	0.120	7.907
M ol.dm ⁻³	308	1.38	2.996×10^{-7}	0.046	0.111	4.713
	313	1.37	3.305×10^{-7}	0.042	0.100	3.885
0.1 M ol.dm ⁻³	298	1.43	0.572×10^{-6}	0.045	0.130	2.537
	303	1.42	0.617×10^{-6}	0.041	0.125	2.172
	308	1.41	0.661×10^{-6}	0.038	0.120	1.895
	313	1.39	0.705×10^{-6}	0.032	0.110	1.526

Table (9): The protection efficiency (P%) values of three different concentration of six inhibitors which add to $2.5x10^{-3}$ mol.dm⁻³ NaOH solution (pH=11.4) at four temperatures.

Table (10): The energy of activation for Al-Si-Cu alloy in 2.5x10⁻³ mol.dm⁻³ NaOH solution in the presence of six different inhibitors with three concentrations for the temperature range (298-313)K.

Fig. (2): Polarization curve for corrosion of Al-Si alloy in 2.5x10⁻³ mol.dmNaOH solution in the presence of CH3COONa at 298K.

Fig. (3): Polarization curve for corrosion of Al-Si alloy in 2.5x10⁻³ mol.dm⁻³NaOH solution in the presence of C₆H₅COONa at 298K.

Fig. (4): Polarization curve for corrosion of Al-Si alloy in 2.5x10⁻³ mol.dm⁻³NaOH solution in the presence of Na₂C₂O₄ at 298K.

Fig. (5): Polarization curve for corrosion of Al-Si alloy in 2.5x10⁻³ mol.dm⁻³NaOH solution in the presence of Na₂CrO₄ at $298K$.

Fig. (6): Polarization curve for corrosion of Al-Si alloy in 2.5x10⁻³ mol.dm⁻³NaOH solution in the presence of Na₂HPO₄ at 298K.

تثبيط تأكل سبيكة المنيوم-سليكون-نحاس في وسط قاعدي باستخدام ستة مثبطات عند اربع درجات حرارية د. رنا عفيف عنائي*

***الجامعة التكنولوجية- قسم هندسة المواد**

الخالصة

يتضمن البحث محاولـة لتثبيط تأكل سبيكة المنيوم-سليكون-نحاس في محلول 2.5×10⁻³ مول دسم³ من هيدروكسيد 0.1 الصوديوم عند اس هيدروجيني مساوياً لـ 11.4 باضافة سنة مثبطات بثلاث تراكيز من كل مثبط هي (1 $\times 10 \times 3$ ، 1 $^{-2}$ ، و مول دسم³). تضمنت المثبطات ثلاث مواد عضوية هي خلات الصوديوم وبنزوات الصوديوم وأوكز الات الصوديوم وثلاث مواد لاعضوية هي كرومات الصوديوم وفوسفات الصوديوم وكبريتات الصوديوم. تم حساب البيانـات التـي تتعلق بالسلوك الاستقطابي والتي تضمنت جهد التأكل وكثافة تيار التأكل وميل تافل الكاثودي والأنودي ومقاومة الأستقطاب. تم ايضماً حساب كفاية الحماية للتثبيط باستخدام المثبطات الستة وقد وضحت قيم طاقة التنشيط تأثير درجة الحرارة على التثبيط في الوسط القاعدي.